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**THEORY OF THE ELECTROLYTIC DEPOSITION OF METALS**  
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**ABSTRACT**—The theory of the electrolytic deposition of metals is presented. The theory is based on the assumption that the rate of deposition is determined by the rate of diffusion of the metal ions to the electrode surface.

**INTRODUCTION**—The theory of the electrolytic deposition of metals is presented. The theory is based on the assumption that the rate of deposition is determined by the rate of diffusion of the metal ions to the electrode surface.

**THEORY**—The theory of the electrolytic deposition of metals is presented. The theory is based on the assumption that the rate of deposition is determined by the rate of diffusion of the metal ions to the electrode surface.

**EXPERIMENTAL**—The theory of the electrolytic deposition of metals is presented. The theory is based on the assumption that the rate of deposition is determined by the rate of diffusion of the metal ions to the electrode surface.

**CONCLUSIONS**—The theory of the electrolytic deposition of metals is presented. The theory is based on the assumption that the rate of deposition is determined by the rate of diffusion of the metal ions to the electrode surface.